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(PTO-1449)

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43889-936	09/551,656

APPLICANT: Takahiro MATSUO, et al.

FILING DATE	GROUP
April 18, 2000	

U.S. PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE
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EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation Yes	Translation No.
	0 691 674	1/10/96	Europe				
	0 515 212	11/25/92	Europe				
	0 519 128	12/23/92	Europe				

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OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

	"Photosensitive Polymers Bearing Iminooxysulfonyl Groups. A Water Soluble Positive-Type Photoresist", by Shirai et al, Die Markomol. Chemie. Macromolecular Chemistry and Physics, Vol. 90, No. 9, pp. 2099-2107 (1989).
	Shirai et al, 114:63167, Chemical Abstracts, America Chemical Society, Columbus, Ohio, Abstract of J. Appl. Polym. Sci. (1990), Vol. 41, No. 9-10, pp. 2527-2532.

EXAMINER	DATE CONSIDERED
	8/20/01

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